### **Electronic Circuits**

Dr. Gökhan Bilgin (Gr.1)

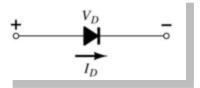
gbilgin@yildiz.edu.tr

Dr. Hamza Osman İlhan (Gr.2)

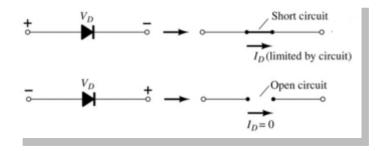
hoilhan@yildiz.edu.tr

### **Diodes**

### The diode is a 2-terminal device.

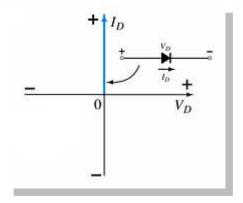


# A diode ideally conducts in only one direction.



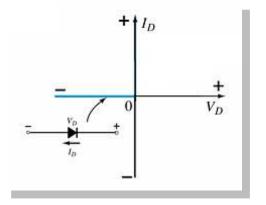
### **Diode Characteristics**

### **Conduction Region**



- The voltage across the diode is 0 V
  - The current is infinite
- The forward resistance is defined as  $R_F = V_F / I_F$ 
  - The diode acts like a short

### **Non-Conduction Region**



- All of the voltage is across the diode
  - The current is 0 A
- The reverse resistance is defined as

$$R_R = V_R / I_R$$

The diode acts like open

### **Semiconductor Materials**

Materials commonly used in the development of semiconductor devices:

- Silicon (Si)
- Germanium (Ge)
- Gallium Arsenide (GaAs)

## **Doping**

The electrical characteristics of silicon and germanium are improved by adding materials in a process called doping.

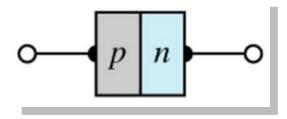
There are just two types of doped semiconductor materials:

- n-type materials contain an excess of conduction band electrons.
  - p-type materials contain an excess of valence band holes.

### p-n Junctions

One end of a silicon or germanium crystal can be doped as a ptype material and the other end as an n-type material.

The result is a p-n junction.

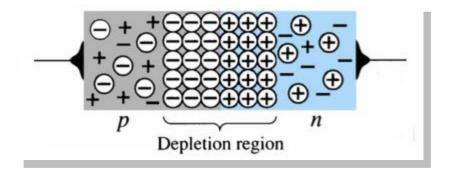


### p-n Junctions

At the *p-n* junction, the excess conduction-band electrons on the *n*-type side are attracted to the valence-band holes on the *p*-type side.

The electrons in the *n*-type material migrate across the junction to the *p*-type material (electron flow).

The electron migration results in a **negative** charge on the p-type side of the junction and a **positive** charge on the n-type side of the junction.



The result is the formation of a depletion region around the junction.

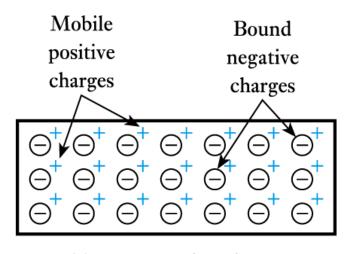
# Doping of semiconductors

### Doping

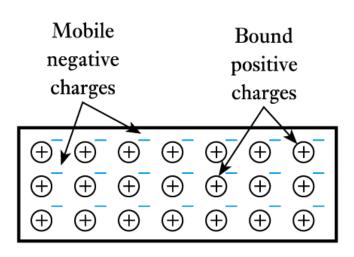
- the addition of small amounts of impurities drastically affects its properties
- some materials form an excess of *electrons* and produce an *n*-type semiconductor
- some materials form an excess of *holes* and produce a *p*-type semiconductor
- both *n*-type and *p*-type materials have much greater conductivity than pure semiconductors
- this is extrinsic conduction.

# Doping of semiconductors (contd.)

- The dominant charge carriers in a doped semiconductor (e.g. electrons in *n*-type material) are called **majority charge carriers**. The other type are **minority charge carriers**.
- The overall doped material is electrically neutral.



(a) p-type semiconductor

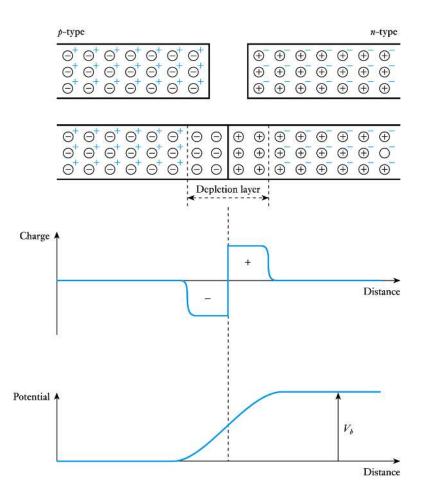


(b) *n*-type semiconductor

## pn Junctions

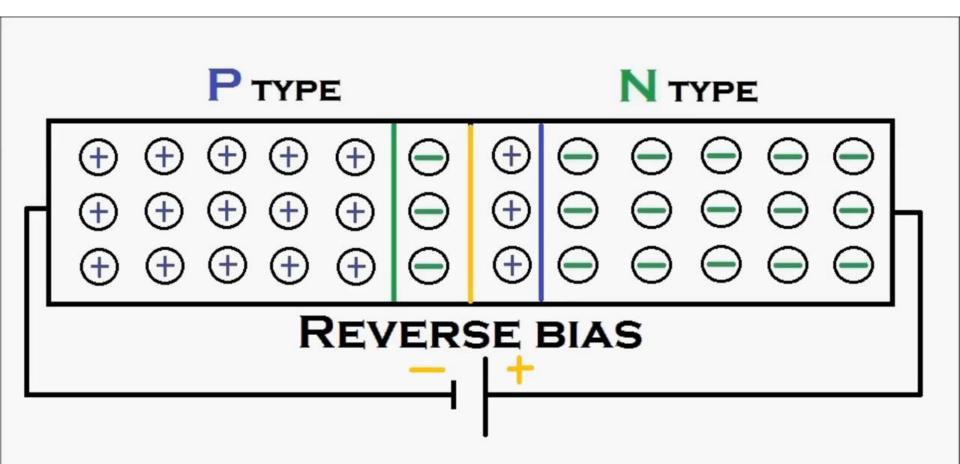
- When p-type and n-type materials are joined, this forms a pn junction
  - the majority charge carriers on each side diffuse across the junction where they combine with (and remove) the charge carriers of the opposite polarity.
  - hence, around the junction there are few free charge carriers and we have a depletion layer (also called a space-charge layer).

- The diffusion of positive charge in one direction and negative charge in the other produces a charge imbalance
  - this results in a potential barrier across the junction.



### Potential barrier

- the barrier opposes the flow of *majority* charge carriers and only a small number have enough energy to surmount it.
  - This generates a small diffusion current.
- the barrier encourages the flow of *minority* carriers and any that come close to it will be swept over
  - This generates a small **drift current**.
- for an isolated junction these two currents must balance each other and the net current is zero.



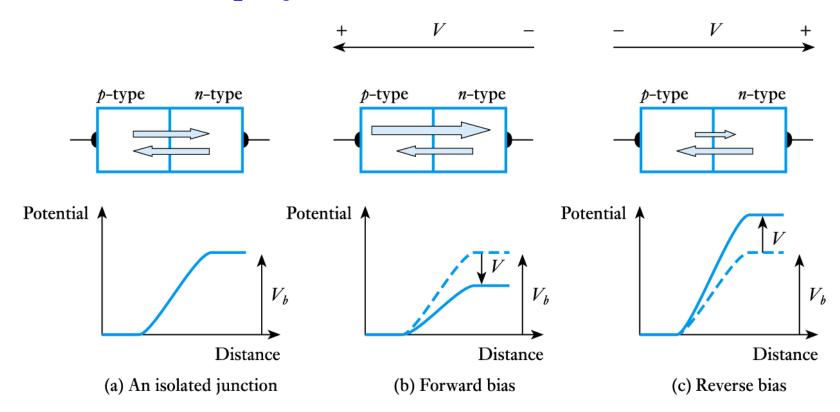
### Forward bias

- if the *p*-type side is made *positive* with respect to the
   *n*-type side the height of the barrier is reduced
- more majority charge carriers have sufficient energy to surmount it
- the diffusion current therefore increases while the drift current remains the same
- there is thus a net current flow across the junction which increases with the applied voltage.

### Reverse bias

- if the *p*-type side is made *negative* with respect to the
   *n*-type side the height of the barrier is increased
- the number of majority charge carriers that have sufficient energy to surmount it rapidly decreases
- the diffusion current therefore vanishes while the drift current remains the same
- thus the only current is a small leakage current caused by the (approximately constant) drift current
- the leakage current is usually negligible (a few nA).

• Currents in a pn junction



### Forward and reverse currents

- pn junction current is given approximately by

$$I = I_s \left( \exp \frac{eV}{\eta kT} - 1 \right)$$

- where I is the current, e is the electronic charge, V is the applied voltage, k is Boltzmann's constant, T is the absolute temperature and  $\eta$  (Greek letter eta) is a constant in the range 1 to 2 determined by the junction material
- for most purposes we can assume  $\eta = 1$ .

• Thus,

$$I \approx I_s \left( \exp \frac{eV}{kT} - 1 \right)$$

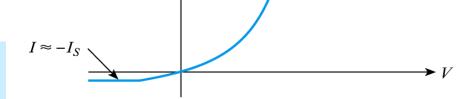
at room temperature  $e/kT \sim 40 \text{ V}^{-1}$ 

• If V > +0.1 V,

$$I \approx I_s \left( \exp \frac{eV}{kT} \right) = I_s \left( \exp 40 V \right)$$

• If  $V \le -0.1 \text{ V}$ ,

$$I \approx I_s (0-1) = -I_s$$



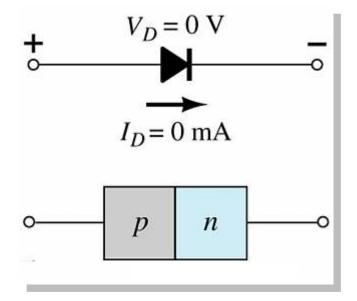
 $-I_S$  is the reverse saturation current.

### A diode has three operating conditions:

- No bias
- Forward bias
- Reverse bias

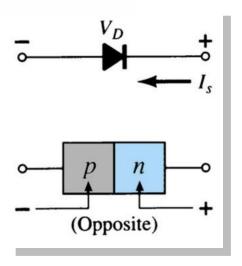
#### No Bias

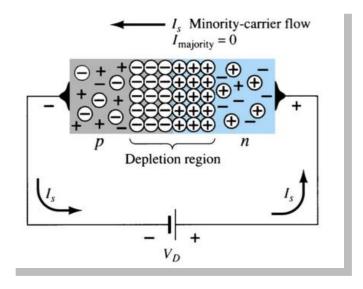
- No external voltage is applied:  $V_D = 0 \text{ V}$ 
  - No current is flowing:  $I_D = 0$  A
- Only a modest depletion region exists



#### **Reverse Bias**

External voltage is applied across the p-n junction in the opposite polarity of the p- and n-type materials.

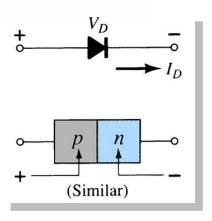


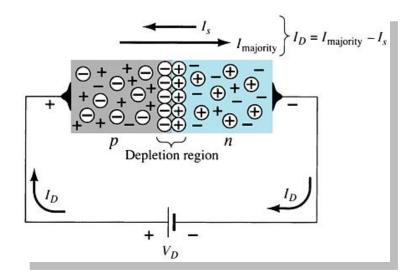


- The reverse voltage causes the depletion region to widen.
- The electrons in the *n*-type material are attracted toward the positive terminal of the voltage source.
- The holes in the *p*-type material are attracted toward the negative terminal of the voltage source.

#### **Forward Bias**

External voltage is applied across the p-n junction in the same polarity as the p- and n-type materials.



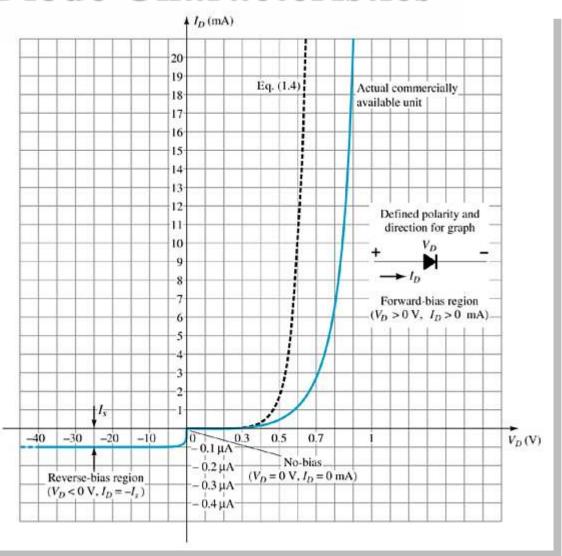


- The forward voltage causes the depletion region to narrow.
- The electrons and holes are pushed toward the *p-n* junction.
  - The electrons and holes have sufficient energy to cross the *p-n* junction.

### **Actual Diode Characteristics**

Note the regions for no bias, reverse bias, and forward bias conditions.

Carefully note the scale for each of these conditions.



### **Majority and Minority Carriers**

Two currents through a diode:

### **Majority Carriers**

- The majority carriers in n-type materials are electrons.
  - The majority carriers in *p*-type materials are holes.

### **Minority Carriers**

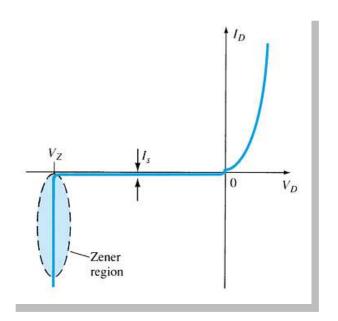
- The minority carriers in n-type materials are holes.
- The minority carriers in *p*-type materials are electrons.

## **Zener Region**

The Zener region is in the diode's reverse-bias region.

At some point the reverse bias voltage is so large the diode breaks down and the reverse current increases dramatically.

- The maximum reverse voltage that won't take a diode into the zener region is called the **peak inverse voltage** or **peak** reverse voltage.
- The voltage that causes a diode to enter the zener region of operation is called the zener voltage (V<sub>z</sub>).



## Forward Bias Voltage

The point at which the diode changes from no-bias condition to forward-bias condition occurs when the electrons and holes are given sufficient energy to cross the *p-n* junction. This energy comes from the external voltage applied across the diode.

### The forward bias voltage required for a:

- gallium arsenide diode  $\cong 1.2 \text{ V}$ 
  - silicon diode  $\approx 0.7 \text{ V}$
  - germanium diode  $\cong 0.3 \text{ V}$

### **Temperature Effects**

As temperature increases it adds energy to the diode.

- It reduces the required forward bias voltage for forwardbias conduction.
- It increases the amount of reverse current in the reversebias condition.
  - It increases maximum reverse bias avalanche voltage.

Germanium diodes are more sensitive to temperature variations than silicon or gallium arsenide diodes.

### **Resistance Levels**

Semiconductors react differently to DC and AC currents.

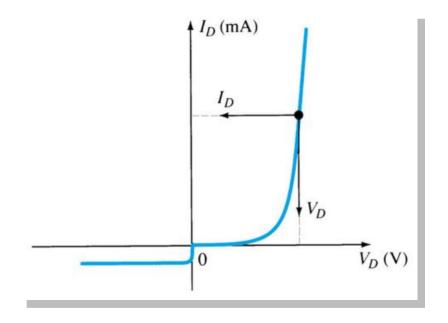
There are three types of resistance:

- DC (static) resistance
- AC (dynamic) resistance
  - Average AC resistance

### DC (Static) Resistance

For a specific applied DC voltage  $V_D$ , the diode has a specific current  $I_D$ , and a specific resistance  $R_D$ .

$$R_D = \frac{V_D}{I_D}$$



## AC (Dynamic) Resistance

In the forward bias region:

$$r_d' = \frac{26\,\mathrm{mV}}{I_D} + r_B$$

- The resistance depends on the amount of current  $(I_D)$  in the diode.
- The voltage across the diode is fairly constant (26 mV for 25°C).
- $r_B$  ranges from a typical 0.1  $\Omega$  for high power devices to 2  $\Omega$  for low power, general purpose diodes. In some cases  $r_B$  can be ignored.

In the reverse bias region:

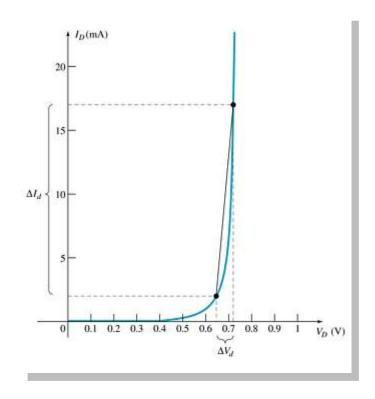
$$\mathbf{r}_{\mathbf{d}}' = \infty$$

The resistance is effectively infinite. The diode acts like an open.

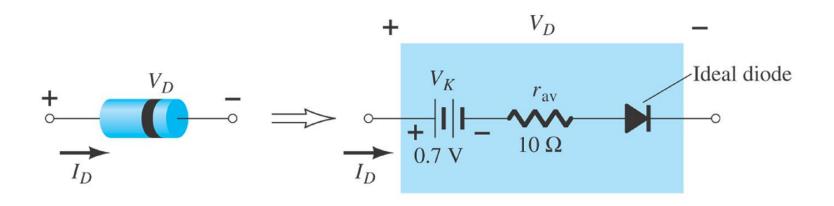
## Average AC Resistance

$$r_{av} = \frac{\Delta V_d}{\Delta I_d}$$
 | pt. to pt.

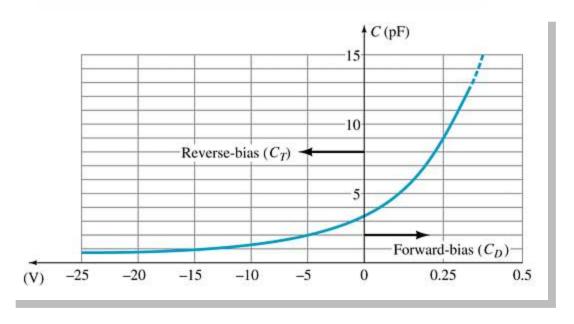
AC resistance can be calculated using the current and voltage values for two points on the diode characteristic curve.



# **Diode Equivalent Circuit**



### **Diode Capacitance**

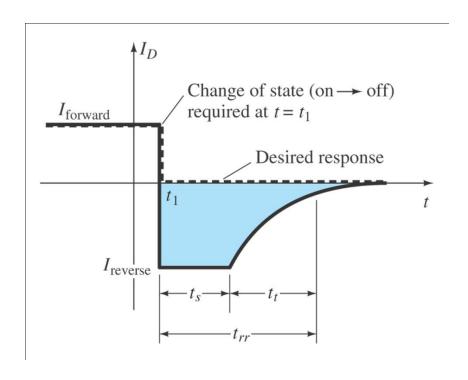


In reverse bias, the depletion layer is very large. The diode's strong positive and negative polarities create capacitance,  $C_T$ . The amount of capacitance depends on the reverse voltage applied.

In forward bias storage capacitance or diffusion capacitance  $(\boldsymbol{C}_{\boldsymbol{D}})$  exists as the diode voltage increases.

## **Reverse Recovery Time (t<sub>rr</sub>)**

Reverse recovery time is the time required for a diode to stop conducting once it is switched from forward bias to reverse bias.



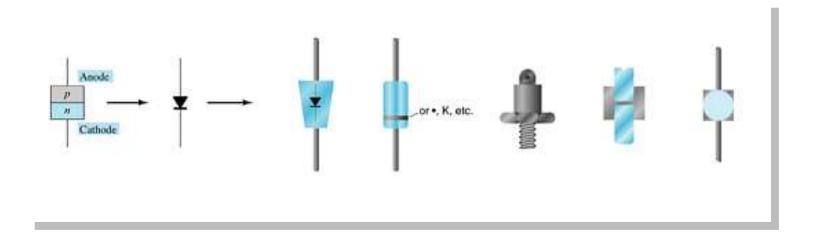
### **Diode Specification Sheets**

Data about a diode is presented uniformly for many different diodes.

This makes cross-matching of diodes for replacement or design easier.

- 1. Forward Voltage (V<sub>F</sub>) at a specified current and temperature
  - 2. Maximum forward current (I<sub>F</sub>) at a specified temperature
  - 3. Reverse saturation current  $(I_R)$  at a specified voltage and temperature
- 4. Reverse voltage rating, PIV or PRV or V(BR), at a specified temperature
  - 5. Maximum power dissipation at a specified temperature
    - 6. Capacitance levels
    - 7. Reverse recovery time,  $t_{rr}$
    - 8. Operating temperature range

## **Diode Symbol and Packaging**



The anode is abbreviated A
The cathode is abbreviated K

# **Diode Testing**

Diode checker Ohmmeter Curve tracer

### **Diode Checker**

Many digital multimeters have a diode checking function.

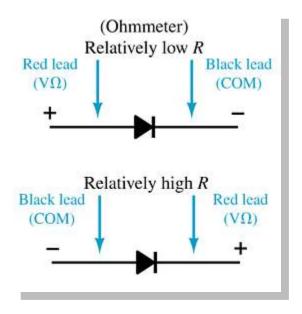
The diode should be tested out of circuit.

A normal diode exhibits its forward voltage:

- Gallium arsenide  $\cong 1.2 \text{ V}$ 
  - Silicon diode  $\approx 0.7 \text{ V}$
- Germanium diode  $\approx 0.3 \text{ V}$

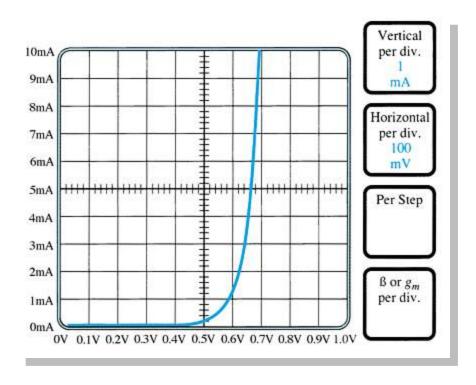
### **Ohmmeter**

An ohmmeter set on a low Ohms scale can be used to test a diode. The diode should be tested out of circuit.



### **Curve Tracer**

A curve tracer displays the characteristic curve of a diode in the test circuit. This curve can be compared to the specifications of the diode from a data sheet.



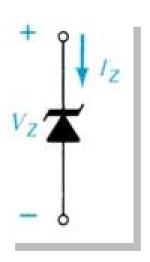
# **Other Types of Diodes**

Zener diode Light-emitting diode Diode arrays

### **Zener Diode**

A Zener is a diode operated in reverse bias at the Zener voltage  $(V_z)$ .

Common Zener voltages are between 1.8 V and 200 V

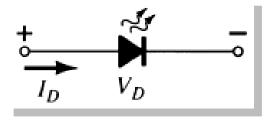


## **Light-Emitting Diode (LED)**

An LED emits photons when it is forward biased.

These can be in the infrared or visible spectrum.

The forward bias voltage is usually in the range of 2 V to 3 V.



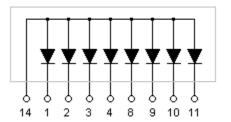
## **Diode Arrays**

Multiple diodes can be packaged together in an integrated circuit (IC).



A variety of combinations exist.

**Common Anode** 



**Common Cathode** 

